

**WEST**

## Freeform Search

**Database:**

US Patents Full-Text Database  
JPO Abstracts Database  
EPO Abstracts Database  
Derwent World Patents Index  
IBM Technical Disclosure Bulletins

**Term:**

hexafluoropropylene and gas and cvd and clean\$

**Display:****Documents in Display Format:****Starting with Number****Generate:** ☐ Hit List ☒ Hit Count ☐ Image

## Search History

**Today's Date:** 10/30/2000

<u>DB Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
USPT	hexafluoropropylene and gas and cvd and clean\$	53	<u>L17</u>
USPT	hexafluoropropylene and gas and cvd	93	<u>L16</u>
USPT	hexafluoropropylene and gas	2478	<u>L15</u>
USPT	hexafluoropropylene	5007	<u>L14</u>
USPT	"cf.sub.3 cfcf.sub.2"	20	<u>L13</u>
USPT	plasma and "cf.sub.3 cfcf.sub.2"	4	<u>L12</u>
USPT	plasma and cvd and perfluoroalkene	1	<u>L11</u>
USPT	clean\$ and gas and perfluoroalkene	14	<u>L10</u>
USPT	clean\$ and perfluoroalkene	24	<u>L9</u>
USPT	cvd and perfluoroalkene	1	<u>L8</u>
USPT	cvd and "cf.sub.3 cfcf.sub.2"	1	<u>L7</u>
USPT	gas and chamber and "cf.sub.3 cfcf.sub.2"	4	<u>L6</u>
USPT	clean\$ and gas and "cfcf.sub.2 cf.sub.3"	10	<u>L5</u>
USPT	clean\$ and gas and "cf.sub.3cfcf.sub.2"	0	<u>L4</u>
USPT	clean\$ and gas and "cf.sub.3 cfcf.sub.2"	4	<u>L3</u>
USPT	clean\$ and cvd and chamber and "cf.sub.3 cfcf.sub.2"	1	<u>L2</u>
USPT	clean\$ and cvd and chamber	4190	<u>L1</u>